

Docket No.: M4065.0018/P018-A

(PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Rodney C. Langley, et al.

Application No.: 09/507,465

Filed: February 22, 2000

For: METHOD AND APPARATUS FOR

PLASMA ETCHING A WAFER

Group Art Unit: 1765

Examiner: M. Anderson

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## **AMENDMENT**

MS Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated August 5, 2003 (Paper No. 27), please amend the above-identified U.S. Patent application as follows.